



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

#10/B
4/24/03
1C

Re the Application of: Katsuhiko ANDO et al.

Group Art Unit: 1712

Serial No.: 09/889,587

Filed: November 20, 2001

RECEIVED
APR 22 2003
GROUP 1700

Examiner: Jeffery Robertson

P.T.O. Confirmation No.: 3002

For: CURABLE RESIN COMPOSITION

AMENDMENT UNDER 37 CFR §1.111

Commissioner for Patents
Washington, D.C. 20231

April 21, 2003

Sir:

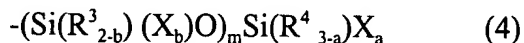
In response to the Office Action dated **January 21, 2003**, please amend the above-identified application as follows:

CLEAN VERSION OF AMENDMENTS

IN THE SPECIFICATION:

Please amend the paragraph on page 2, line 26 as follows:

6¹
The term "reactive silicon group" in the context of the present invention means any group capable of forming a siloxane bond upon intergroup condensation and, as such, is not particularly restricted. However, the group represented by the following general formula (4) can be mentioned as a typical example.



(wherein R^3 and R^4 each represents an alkyl group containing 1 to 20 carbon atoms, an aryl group containing 6 to 20 carbon atoms, an aralkyl group containing 7 to 20 carbon atoms or a triorganosiloxy group of the formula $(\text{R}')_3\text{SiO}-$; when two or more R^3 and R^4 groups are present, they